

02/04/2003

RELIABILITY REPORT FOR

DS1805, Rev A1

Dallas Semiconductor

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Prepared by:

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Conclusion:

The following qualification successfully meets the quality and reliability standards required of all Dallas Semiconductor products and processes:

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In addition, Dallas Semiconductor's continuous reliability monitor program ensures that all outgoing product will continue to meet Maxim's quality and reliability standards. The current status of the reliability monitor program can be viewed at http://www.maxim-ic.com/TechSupport /dsreliability.html.

Device Description:

A description of this device can be found in the product data sheet. You can find the product data sheet at http://dbserv.maxim-ic.com/l_datasheet3.cfm.

Reliability Derating:

The Arrhenius model will be used to determine the acceleration factor for failure mechanisms that are temperature accelerated.

AfT = exp((Ea/k)*(1/Tu - 1/Ts)) = tu/ts AfT = Acceleration factor due to Temperature tu = Time at use temperature (e.g. 55°C) ts = Time at stress temperature (e.g. 125°C) k = Boltzmann's Constant (8.617 x 10-5 eV/°K) Tu = Temperature at Use (°K) Ts = Temperature at Stress (°K) Ea = Activation Energy (e.g. 0.7 ev)

The activation energy of the failure mechanism is derived from either internal studies or industry accepted standards, or activation energy of 0.7ev will be used whenever actual failure mechanisms or their activation energies are unknown. All deratings will be done from the stress ambient temperature to the use ambient temperature.

An exponential model will be used to determine the acceleration factor for failure mechanisms, which are voltage accelerated.

AfV = exp(B*(Vs - Vu)) AfV = Acceleration factor due to Voltage Vs = Stress Voltage (e.g. 7.0 volts) Vu = Maximum Operating Voltage (e.g. 5.5 volts) B = Constant related to failure mechanism type (e.g. 1.0, 2.4, 2.7, etc.)

The Constant, B, related to the failure mechanism is derived from either internal studies or industry accepted standards, or a B of 1.0 will be used whenever actual failure mechanisms or their B are unknown. All deratings will be done from the stress voltage to the maximum operating voltage. Failure rate data from the operating life test is reported using a Chi-Squared statistical model at the 60% or 90% confidence level (Cf).

The failure rate, Fr, is related to the acceleration during life test by:

Fr = X/(ts * AfV * AfT * N * 2)X = Chi-Sq statistical upper limit N = Life test sample size Failure Rates are reported in FITs (Failures in Time) or MTTF (Mean Time To Failure). The FIT rate is related to MTTF by:

MTTF = 1/Fr

NOTE: MTTF is frequently used interchangeably with MTBF.

The calculated failure rate for this device/process is:

FAILURE RATE:	MTTF (YRS): 9400	FITS: 12.1
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The parameters used to calculate this failure rate are as follows:

Cf: 60% Ea: 0.7 B: 0	Tu: 25 °C	Vu: 5.5 Volts
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The reliability data follows. A the start of this data is the device information. This is a description of the device either used as a reliability test vehicle for a process / assembly qualification / monitor or a device used as part of a product qualification / monitor. Following this is the assembly information. This section includes a description of the assembly vehicle used to generate this reliability data for both qualification / monitor. The next section is the detailed reliability data for each stress found in the qualification / monitor. If there are additional processes or assemblies used as part of this report, a description of each will follow which includes the respective reliability data for that process/ assembly. The reliability data section includes the latest data available.

Device Informatio	n:					
Device: Process: Passivation: Die Size: Number of Trans Interconnect: Gate Oxide Thic		DS1805 D6H-2P2M,HPVt,TCZ PBL:GOI Passivation w/Nov TEOS Oxide-Nitride 97 x 38 8212 Aluminum / 1% Silicon / 0.5% Copper 150 Å				
Assembly Informa	ation:					
Assembly Information: Qualification Vehicle: Assembly Site: Pin Count: Package Type: Body Size: Mold Compound: Lead Frame: Lead Frame: Lead Finsh: Die Attach: Bond Wire / Size: Flammability: Moisture Sensitivity		DS1805 ATP (Amkor, PI) 16 SOIC 150x1.4 Sumitomo 6300H Stamped Copper CDA194 SnPb Plate 84-1 LMISR4 Epoxy Silverfilled Ablebond Au / 1.3 mil UL 94-V0 Level 1				
(JEDEC J-STI Date Code Rang	,	0210 to 0210				
ELECTRICAL CHAR		ATION				
DESCRIPTION		CODE CONDITION	RE	ADPOINT	QUANTITY	FAILS
ESD SENSITIVITY	0210	EOS/ESD S5.1 HBM 500 VOLTS	1	PULSES	6 3	0
ESD SENSITIVITY	0210	EOS/ESD S5.1 HBM 1000 VOLTS	1	PULSES	3 3	0
ESD SENSITIVITY	0210	EOS/ESD S5.1 HBM 2000 VOLTS	1	PULSES	5 3	0

DESCRIPTION	DATE CODE CONDITION		READPOINT QUANTITY FAILS				
HIGH TEMPERATURE OPERATING LIFE							
				Total:		5	
LATCH-UP	0210	JESD78, Vsupply TEST 125C			3	0	
LATCH-UP	0210	JESD78, I-TEST 125C			3	0	
ESD SENSITIVITY	0210	EOS/ESD S5.1 HBM 8000 VOLTS	1	PULSES	3	3	
ESD SENSITIVITY	0210	EOS/ESD S5.1 HBM 4000 VOLTS	1	PULSES	3	2	

HIGH VOLTAGE LIFE	0210	125C, 6.0 VOLTS		1000	HOURS	80	0
					Total:		0
FAILURE RATE:	МТТ	F (YRS): 9400	FITS: 12.	.1			